

	Type	L #	Hits	Search Text	DBs	Time Stamp	Co mm en ts	Er ro r De fi ni ti on	Er ro rs
1	IS&R	L1	871	(438/542).CCLS.	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	2005/09/30 02:38			
2	IS&R	L2	363	(438/308).CCLS.	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	2005/09/30 02:39			
3	IS&R	L3	499	(438/309).CCLS.	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	2005/09/30 02:39			
4	BRS	L4	25	(438/542).ccls. and mos and epitaxial\$4	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	2005/09/30 02:40			
5	BRS	L5	33	(438/308).ccls. and mos and epitaxial\$4	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	2005/09/30 02:40			
6	BRS	L6	101	(438/309).ccls. and mos and epitaxial\$4	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	2005/09/30 02:40			

	Type	L #	Hits	Search Text	DBs	Time Stamp	Co mm en ts	Er ro r De fi ni ti on	Er ro rs
7	BRS	L7	88	(438/309).ccls. and mos and epitaxial\$4 and dop\$4	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	2005/09/30 02:41			
8	BRS	L8	21	(438/309).ccls. and mos and epitaxial\$4 and dop\$4 and (bury\$3 or buri\$3) with oxide	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	2005/09/30 02:44			
9	BRS	L9	0	(438/309).ccls. and mos and (heat\$4 or anneal\$4 or thermal) with (epitaxial\$4 or grow\$4 with (\$4crystal or \$4crystalline)) with (bury\$3 or buri\$3) with oxide	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	2005/09/30 02:48			

	Type	L #	Hits	Search Text	DBs	Time Stamp	Comments	Error Definition	Errors
10	BRS	L10	64	mos and (heat\$4 or anneal\$4 or thermal) with (epitaxial\$4 or grow\$4 with (\$4crystal or \$4crystalline)) with (bury\$3 or buri\$3) with oxide	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	2005/09/30 02:49			
11	BRS	L11	38	("438"/\$).ccls. and mos and (heat\$4 or anneal\$4 or thermal) with (epitaxial\$4 or grow\$4 with (\$4crystal or \$4crystalline)) with (bury\$3 or buri\$3) with oxide	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	2005/09/30 02:49			

	Type	L #	Hits	Search Text	DBs	Time Stamp	Comments	Error Definition	Errors
12	BRS	L12	29	("438"/\$).ccls. and mos and (heat\$4 or anneal\$4 or thermal) with (epitaxial\$4 or grow\$4 with (\$4crystal or \$4crystalline)) with (bury\$3 or buri\$3) with oxide and dop\$4	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	2005/09/30 02:49			
13	BRS	L13	50	mos and (heat\$4 or anneal\$4 or thermal) with (epitaxial\$4 or grow\$4 with (\$4crystal or \$4crystalline)) with (bury\$3 or buri\$3) with oxide and dop\$4	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	2005/09/30 03:00			

	Type	L #	Hits	Search Text	DBs	Time Stamp	Comments	Error Definition	Errors
14	BRS	L14	11	(mos and (heat\$4 or anneal\$4 or thermal) and (epitaxial\$4 or grow\$4 with (\$4crystal or \$4crystalline)) and (bury\$3 or buri\$3) with oxide and dop\$4).clm.	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	2005/09/30 03:01			